

Low dose gamma irradiation study of ATLAS ITk MD8 diodes

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Motivation:

- Results from previous studies of gamma-irradiated diodes show that bulk current increases linearly with total ionizing dose (TID), while surface current saturates [1]. Unfortunately, the minimum TID in that study was 66 Mrad, making it impossible to determine at what TID surface current saturates. Studies of gamma-irradiated main bare sensors, ATLAS18 [2] and sensors on modules [3] showed a steep increase in total current already at low TIDs.
- This study shows detailed measurements of total, bulk, and surface currents in MD8 diodes after multiple low-dose gamma irradiations.
- The study also explores the dependence on temperature and annealing.

Samples:

- n^+in-p float zone diodes MD8 from the ATLAS18 production wafers:
 - MD8 with p-stop implant between Bias (BR) and Guard Rings (GR) – MD8p
 - regular MD8 without p-stop – MD8

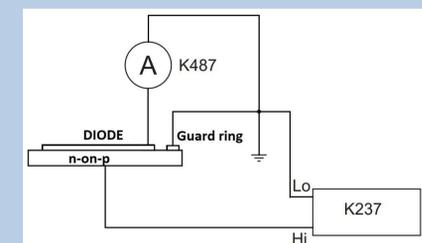


Irradiation:

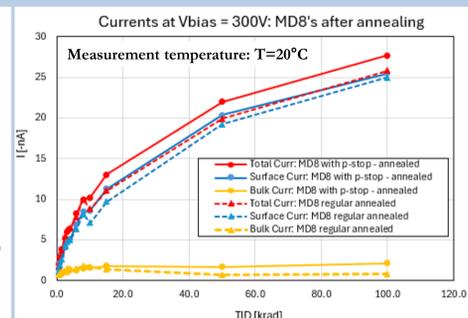
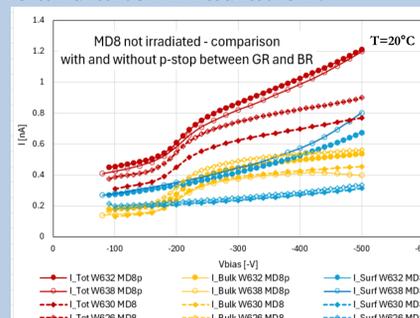
- Samples irradiated by ⁶⁰Co gamma
- TID: 14 doses 0.5 – 100krad
- Temperature < 35 °C
- Dose rate: 1.60 krad/min (up to 8 krad) and 8.5 krad/min (from 10 to 100 krad) in Si
- Dose rate uncertainty: <5%
- Irradiation in Charge Particle Equilibrium box according to ESA/SCC Basic Spec. No. 22900
- Dose enhancement from low-energy scattered radiation is minimised by producing electron equilibrium
- Uniform distribution of energy deposited in samples is ensured



Bulk, surface and total currents before and after irradiation:



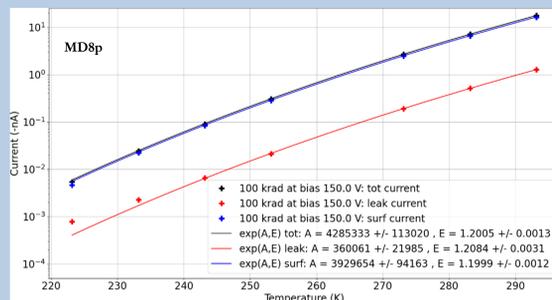
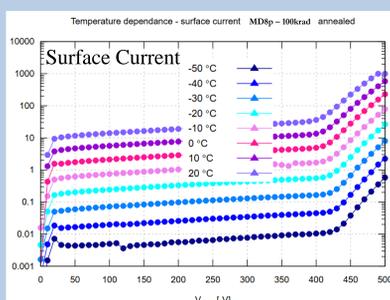
- Great care was taken to properly determine bulk current flowing through active volume of diode (I_{bulk}) bounded by guard ring and surface current dominating outside of this guard ring (I_{sur})
- Setup enables readings of total and bulk currents.
- Surface current is obtained as $I_{sur} = I_{tot} - I_{bulk}$.



- Before irradiation of MD8 diode, bulk and surface currents are comparable in magnitude.
- Surface current is slightly larger in diodes with p-stop between BR and GR than in regular diodes.
- After irradiation, the surface current increases significantly even at the low TID.
- Bulk current remains relatively stable up to measured TID of 100 krad.

Temperature dependence of Total, Surface and Bulk currents after gamma irradiation

- Temperature dependence of current generated in Si bulk is summarized in [4] for proton and neutron irradiated silicon.
- In this study temperature dependence of total, surface and bulk currents after gamma irradiation were studied.



Temperature dependence of currents was measured in range -50°C - +20°C in MD8p diode and fitted by $I(T) = AT^2 \exp(-\frac{E}{2kT})$, where k is Boltzmann constant ($k = 8.617 \times 10^{-5} \text{ eV} \cdot \text{K}^{-1}$) with free parameters A and activation energy E for total, surface and bulk currents.

MD8p	E_{TOT} [eV]	E_{BULK} [eV]	E_{SURF} [eV]	$A_{TOT}[\text{nA/K}^2] \times 10^6$	$A_{BULK}[\text{nA/K}^2] \times 10^6$	$A_{SURF}[\text{nA/K}^2] \times 10^6$
10krad	1.209	1.192	1.211	2.101	0.166	1.951
50krad	1.184	1.172	1.185	2.281	0.137	2.148
100krad	1.201	1.208	1.200	4.285	0.360	3.930

Assumption:

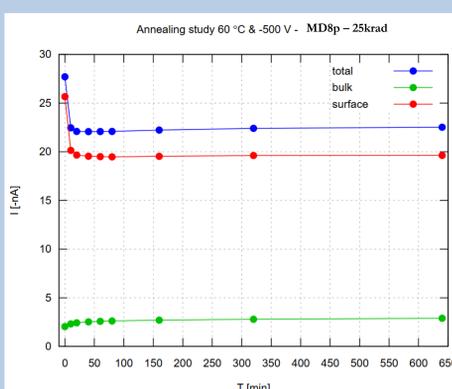
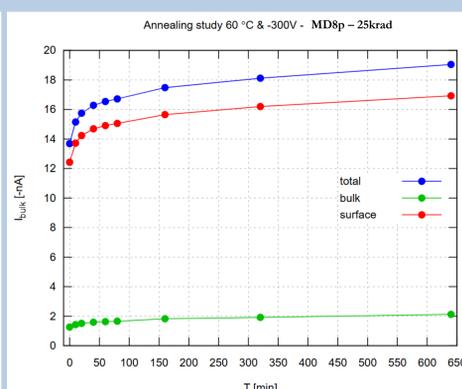
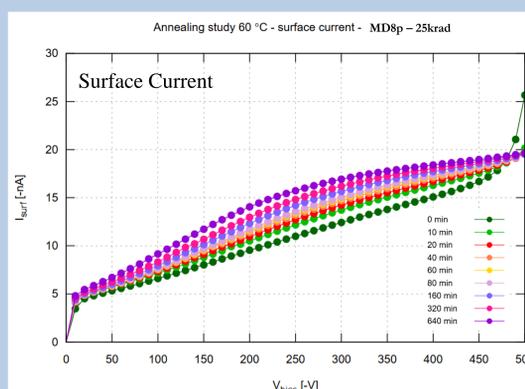
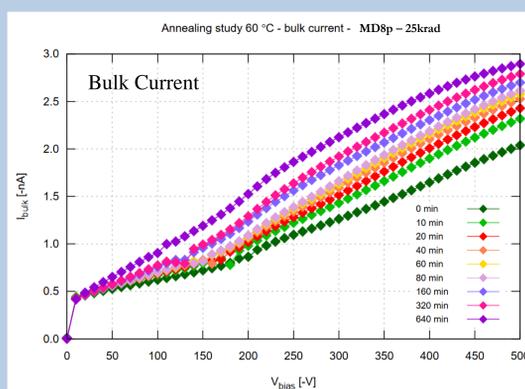
- E may differ for I_{BULK} , I_{SURF} and I_{TOT} due to presence of the SiO₂ layer in surface.
- E may vary with dopant concentration. However, no significant change in radiation formed defects in bulk is expected after low gamma doses.

Results:

- No differences in activation energy were observed in temperature dependence fit for total, surface, and bulk currents.

Annealing at 60°C:

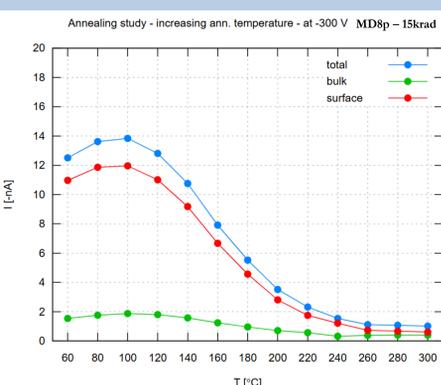
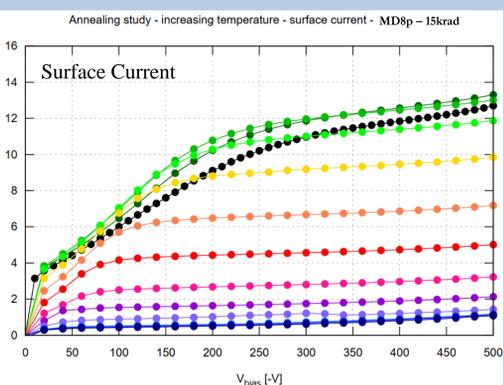
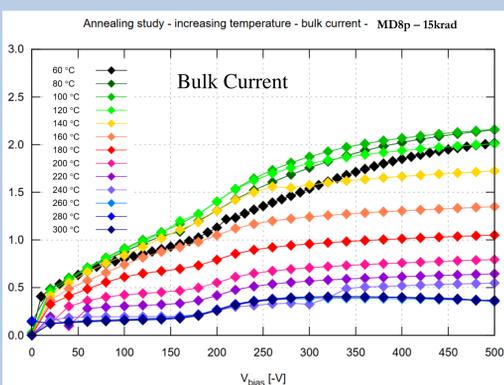
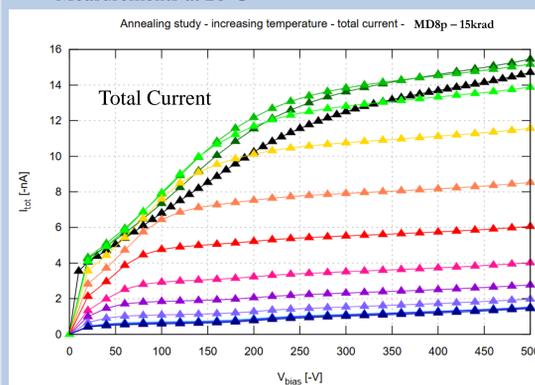
- MD8 diode irradiated to 25krad underwent controlled annealing at 60°C for 10, 20, 40, 60, 80, 160, 320, and 640 minutes.
- Bulk current is slightly increasing with increasing time of annealing at 60°C
- The surface current at 480V has no annealing. Annealing is decreasing the soft-breakdown at higher voltage?



Annealing at increasing temperature 60°C - 300°C:

- MD8p diode irradiated to 15krad underwent annealing for 80 minutes at 60°C and after that isochronal annealing for 20 min at different temperatures, between 80 °C and 300 °C. Temperature was increased in steps of 20 °C.
- Measurements at 20°C

- Total, bulk, and surface currents show a slight increase up to 100°C, but at higher temperatures, currents decrease significantly, and return to levels comparable to those before irradiation
- Next steps: annealing at constant temperature 160°C



Conclusions:

- Pre-Irradiation:** The bulk and surface currents are comparable in magnitude.
- Post-Irradiation:** Total, bulk, and surface currents increases with increasing TID. At low TIDs, increase in total current is primarily driven by increase in surface current.
- No differences in activation energy for total, surface, and bulk currents were observed in temperature dependence fit for MD8 diodes.
- Annealing at 60°C:** Total, bulk, and surface currents show a slight increase with annealing time.
- Annealing at higher temperatures:** Total, bulk, and surface currents measured in full depletion conditions increase slightly for annealing temperatures up to 100°C. At temperatures > 100°C, all three currents decrease significantly, returning to levels comparable to pre-irradiation values. Radiation-induced defects in both bulk and surface, caused by gamma irradiation, seems to be completely annealed at high temperatures.

Acknowledgement:

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References:

- M. Mikeštková, et al., The study of gamma-radiation induced displacement damage in n⁺-in-p silicon diodes, NIMA1064 (2024) 169432
- M. Mikeštková, et al. Gamma irradiation of ATLAS18 ITk strip sensors affected by static charge, PoS(VERTEX2023) (2024) 026
- E. Duden, Gamma irradiation of ITK silicon strip modules with early breakdown, poster at LHCP2024
- A Chilingarov, Temperature dependence of the current generated in Si bulk, (2013) JINST 8 P10003